		W
	Application No.	Applicant(s)
Notice of Allowability	10/033,975	HARRISON ET AL.
	Examiner	Art Unit
	Hoa Q. Pham	2877
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS nerewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F of the Office or upon petition by the applicant. See 37 CFR 1.31	S (OR REMAINS) CLOSED in i) or other appropriate commining the commining of the commining o	n this application. If not included unication will be mailed in due course. THIS
1. This communication is responsive to		
2. X The allowed claim(s) is/are <u>1-31</u> .		
3. $igotimes$ The drawings filed on <u>12/19/01</u> are accepted by the Exam	niner.	
4. Acknowledgment is made of a claim for foreign priority unit a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 1. Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submined in the submined of the priority of the Notice of Draftspering (a) including changes required by the Notice of Draftspering including changes required by the Notice of Draftspering including changes required by the attached Examine Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in DEPOSIT OF and/or INFORMATION about the depattached Examiner's comment regarding REQUIREMENT	re been received. re been received in Application ocuments have been received " of this communication to file MENT of this application. mitted. Note the attached EX ves reason(s) why the oath of ust be submitted. rson's Patent Drawing Reviet —. r's Amendment / Comment of the header according to 37 Ci osit of BIOLOGICAL MAT	on No In No In In this national stage application from the din this national stage application from the ear reply complying with the requirements AMINER'S AMENDMENT or NOTICE OF redeclaration is deficient. In (PTO-948) attached In the Office action of the drawings in the front (not the back) of FR 1.121(d). ERIAL must be submitted. Note the
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB Paper No./Mail Date 11-02-2002 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material) 6. Interview S Paper No /08), 7. Examiner's	Informal Patent Application (PTO-152) Jummary (PTO-413), /Mail Date Jamendment/Comment Statement of Reasons for Allowance Hoa Q. Pham
		Primary Examiner Art Unit: 2877



Application/Control Number: 10/033,975

Art Unit: 2877

REASONS FOR ALLOWANCE

1. The following is an examiner's statement of reasons for allowance:

There was no prior art found by the examiner that suggested modification or combination with the cited art so as to satisfy the combination of all the limitations in claims 1, 11, 15, 22 and 25.

As to claims 1 and 11, the prior art of record, taken alone or in combination, fails to disclose or render steps or limitations "a pump light source directing a pump light beam toward selected locations on the wafer, a light detector for detecting light emitted from the wafer; and a pump beam aiming mechanism selectively varying a position at which the pump light beam enters the wafer", in combination with the rest of the limitations of claims 1 and 11.

As to claims 15, 22 and 25, same reasons as to claims 1 and 11 above, in addition the prior art of record, taken alone or in combination, fails to disclose or render steps or limitations "growing epitaxial layers on a substrate defining at least a mirror region and an active gain region" and "performing post-epitaxial growth processing on at least one of the substrate and the epitaxial layers".

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Application/Control Number: 10/033,975

Art Unit: 2877

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hoa Q. Pham whose telephone number is (571) 272-2426. The examiner can normally be reached on 7:30AM to 6 PM, Monday through Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Frank G. Font can be reached on (571) 272-2415. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Hoa Q. Pham Primary Examiner

Art Unit 2877

HP March 6, 2004